			DB	Time stamp /
L Number	Hits	Search Text		
1	18438	silica near3 colloid\$3	USPAT; US-PGPUB	2002/09/09
2	68870	(hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USPAT; US-PGPUB	2002/09/09
3	2025	(silica near3 colloid\$3) and ((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USPAT; US-PGPUB	2002/09/09 08:27
4	10928	teos	USPAT; US-PGPUB	2002/09/09 08:27
5	148	tetra\$1ethylsilicate	USPAT; US-PGPUB	2002/09/09 08:28
6	755	silicate adj ester	USPAT; US-PGPUB	2002/09/09 08:28
7	11800	teos tetra\$lethylsilicate (silicate adj	USPAT; US-PGPUB	2002/09/09 08:28
8	70	((silica near3 colloid\$3) and ((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USPAT; US-PGPUB	2002/09/09 08:28
9	131)) and (teos tetra\$lethylsilicate (silicate adj ester)) (silica near3 colloid\$3) same ((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USPAT; US-PGPUB	2002/09/09 08:29
10	31753	low near3 metal	USPAT; US-PGPUB	2002/09/09 08:29
11	9	((silica near3 colloid\$3) same ((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USPAT; US-PGPUB	2002/09/09 08:34
12	108)) and (low near3 metal) (516/81).CCLS.	USPAT; US-PGPUB	2002/09/09
13	0	Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USPAT; US-PGPUB	2002/09/09 08:35
14	11958) and ((516/81).CCLS.) biocid\$5	USPAT; US-PGPUB	2002/09/09 08:49
15	238	((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff) same biocid\$5	USPAT; US-PGPUB	2002/09/09

				2002/09/09
16		((silica near3 colloid\$3) and ((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff)) and (((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff) same biocid\$5)	USPAT; US-PGPUB	2002/09/09
17	231774	silica	USPAT; US-PGPUB	08:48
18	2342	<pre>(teos tetra\$lethylsilicate (silicate adj ester)) and silica</pre>	USPAT; US-PGPUB	2002/09/09 08:48
19	2	(((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff) same biocid\$5) and ((teos tetra\$1ethylsilicate (silicate adj ester)) and silica)	USPAT; US-PGPUB	2002/09/09 08:48
20	19093	(hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USOCR	2002/09/09 08:51
21	1329	biocid\$5	USOCR	2002/09/09
22	33	((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USOCR	2002/09/09 08:50
23	57243) same biocid\$5 silica	USOCR	2002/09/09 08:51
24	5	(((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	USOCR	2002/09/09 08:57
25	32488) same biocid\$5) and silica (hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff	EPO; JPO; DERWENT	2002/09/09 08:51
26	5330	biocid\$5	EPO; JPO; DERWENT	2002/09/09
27	130925	silica	EPO; JPO; DERWENT	2002/09/09
28	1	((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff) and biocid\$5 and silica	EPO; JPO; DERWENT	2002/09/09 08:57
29	92682		EPO; JPO; DERWENT	2002/09/09
30	1	((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff) and biocid\$5 and polish\$4	EPO; JPO; DERWENT	2002/09/09 08:57

31	47801	polish\$4	USOCR	2002/09/09
32	1	(((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff) same biocid\$5) and polish\$4	USOCR	2002/09/09
33	101297		USPAT; US-PGPUB	2002/09/09 08:58
34	21	(((hydrogen adj peroxide) H?sub.20?sub.2 Albone (dihydrogen adj dioxide) Hioxy (hydrogen adj dioxide) Hydroperoxide Inhibine Oxydol Perhydrol Peroxan superoxol t-stuff) same biocid\$5) and polish\$4	USPAT; US-PGPUB	2002/09/09 08:58

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        Apr 22 BIOSIS Gene Names now available in TOXCENTER
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                PCTFULL has been reloaded
        Jun 10
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NEWS 13 Jul 22
                 saved answer sets no longer valid
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                CANCERLIT reload
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                PHARMAMarketLetter(PHARMAML) - new on STN
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                NTIS has been reloaded and enhanced
        Aug 08
NEWS 18
                Aquatic Toxicity Information Retrieval (AQUIRE)
NEWS 19
        Aug 19
                 now available on STN
                 IFIPAT, IFICDB, and IFIUDB have been reloaded
NEWS 20
        Aug 19
                 The MEDLINE file segment of TOXCENTER has been reloaded
        Aug 19
                 Sequence searching in REGISTRY enhanced
NEWS 22
        Aug 26
                 JAPIO has been reloaded and enhanced
NEWS 23
        Sep 03
              February 1 CURRENT WINDOWS VERSION IS V6.0d,
NEWS EXPRESS
              CURRENT MACINTOSH VERSION IS V6.0a(ENG) AND V6.0Ja(JP),
              AND CURRENT DISCOVER FILE IS DATED 05 FEBRUARY 2002
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Calculated physical property data is now available. See HELP PROPERTIES for more information. See STNote 27, Searching Properties in the CAS Registry File, for complete details: http://www.cas.org/ONLINE/STN/STNOTES/stnotes27.pdf

=> s silica
L1 5694 SILICA

=> s collodal silica/cn
L2 0 COLLODAL SILICA/CN

=> s colloidal silica/cn
L3 1 COLLOIDAL SILICA/CN

=> d

L3

7631-86-9 REGISTRY RN Silica (6CI, 7CI, 8CI, 9CI) (CA INDEX NAME) CN OTHER NAMES: 1165MP CN CN 175GR CN 300CF 30R50 CN 30R7 CN CN 3K CN 3KS 400WO CN CN 5X 937L CN 940UP CN

CN 955W CN 980H CN A 175 CN A 200 CN A 300 CN A 380 CN Acemat

CN Acematt HK 400 CN Acematt OK 607 CN Acematt TS 100

CN Acticel

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Adelite 20N
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CN
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CN
     Colloidal silica
     Zeosil 1165MD
ADDITIONAL NAMES NOT AVAILABLE IN THIS FORMAT - Use FCN, FIDE, or ALL for
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      3D CONCORD
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      330152-64-2, 341028-71-5, 368432-40-0
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LC
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        CEN, CHEMCATS, CHEMINFORMRX, CHEMLIST, CHEMSAFE, CIN, CSCHEM, CSNB,
        DDFU, DETHERM*, DIOGENES, DRUGU, EMBASE, ENCOMPLIT, ENCOMPLIT2,
        ENCOMPPAT, ENCOMPPAT2, GMELIN*, HSDB*, IFICDB, IFIPAT, IFIUDB, IPA,
        MEDLINE, MRCK*, MSDS-OHS, NAPRALERT, NIOSHTIC, PHARMASEARCH, PIRA,
        PROMT, RTECS*, TOXCENTER, TULSA, ULIDAT, USAN, USPAT2, USPATFULL, VETU,
        VTB
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Other Sources: DSL**, EINECS**, TSCA**
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242583 REFERENCES IN FILE CA (1967 TO DATE)
4822 REFERENCES TO NON-SPECIFIC DERIVATIVES IN FILE CA
242939 REFERENCES IN FILE CAPLUS (1967 TO DATE)
1 REFERENCES IN FILE CAOLD (PRIOR TO 1967)

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=> s 13 L5 243045 L3 => s 14 L6 63323 L4 => s 15 and 16 L7 1459 L5 AND L6 => s biocid### L8 7740 BIOCID###

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=> s 17 and 18
            5 L7 AND L8
L9
=> d bib,ab 1-5
     ANSWER 1 OF 5 CAPLUS COPYRIGHT 2002 ACS
L9
     2002:112881 CAPLUS
AN
     136:155055
DN
     Colloidal silica slurries showing excellent storage stability used as
ΤI
     polishing agents for semiconductor device fabrication
     Matsumura, Shigetoyo; Okada, Yukio; Managi, Tatsuo; Toyama, Keiji; Sakai,
TN
     Masatoshi
     Fuso Chemical Co., Ltd., Japan
PA
     Jpn. Kokai Tokkyo Koho, 5 pp.
SO
     CODEN: JKXXAF
     Patent
DT
     Japanese
T.A
FAN.CNT 1
                                           APPLICATION NO.
                                                            DATE
                      KIND DATE
     PATENT NO.
                                           _____
                                                            _____
                      ____
                                           JP 2000-236454
                                                            20000804
                            20020212
                       A2
     JP 2002045681
PΙ
                                                            20010115
                                           US 2001-761043
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     US 2002037935
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     DE 10115327
                                                            20010718
                                           FR 2001-9620
                            20020208
     FR 2812563
                       A1
                                           CN 2001-123727
                                                            20010730
                            20020227
                       Α
     CN 1337437
                            20000804
                       Α
PRAI JP 2000-236454
     The colloidal silica slurries contain 5-100 ppm of H2O2. The slurries are
     free from corrosive antimicrobial agents which damage Si wafers and wiring
     on them.
     ANSWER 2 OF 5 CAPLUS COPYRIGHT 2002 ACS
Ь9
                                                                 see us good oo 259 be
     2001:618111 CAPLUS
ΑN
     135:169833
 DN
     Biocide additives for bacterial and fungal protection of
     abrasive slurries used in chemical mechanical polishing of wafer
     Luo, Qiuliang; Goldberg, Wendy B.; Ye, Qianqiu
 IN
      Rodel Holdings, Inc., USA
 PA
      PCT Int. Appl., 11 pp.
      CODEN: PIXXD2
 DT
      Patent
 LA
      English
 FAN.CNT 1
                                            APPLICATION NO.
                                                             DATE
                       KIND
                             DATE
      PATENT NO.
      ______
                                                             20010202
                                            WO 2001-US3381
                             20010823
                       A1
      WO 2001060940
 PΙ
          W: JP, KR
          RW: AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL,
              PT, SE, TR
                                            US 2001-775865
                                                             20010202
                             20020228
      US 2002025762
                        A1
                             20000216
 PRAI US 2000-182960P
                       P
      Compds. contg. both a sulfur and a nitrogen in a five-membered ring
      structure (such as 2-methyl-4-isothiazolin-3-one and 5-chloro-2-methyl-4-
      isothiazolin-3-one) are used as biocides in chem. mech.
      polishing solns. and slurries. Polishing and abrasive performance of W,
      Ti, SiO2 and Cu wafers are unaffected or slightly improved by addn. of
      those biocides. Addn. of 0.01-1 wt.% of the biocides
```

in polishing slurries is shown to prevent any bacterial and fungal activity up to 14 days. THERE ARE 9 CITED REFERENCES AVAILABLE FOR THIS RECORD RE.CNT 9 ALL CITATIONS AVAILABLE IN THE RE FORMAT ANSWER 3 OF 5 CAPLUS COPYRIGHT 2002 ACS L9 2001:136933 CAPLUS ΑN 134:174244 DN Biocidal and absorbent/catalyst compositions containing a TI biocidal metal compound, a support and a reducing agent Kepner, Bryan E.; Mintz, Eric A. IN Apyron Technologies, Inc., USA PΑ PCT Int. Appl., 111 pp. SO CODEN: PIXXD2 Patent DTEnglish LΑ FAN.CNT 1 APPLICATION NO. DATE KIND DATE PATENT NO. _____ _____ ____ WO 2000-US21861 20000810 20010222 WO 2001011955 A2 PΤ **A**3 20010607 WO 2001011955 AE, AG, AL, AM, AT, AU, AZ, BA, BB, BG, BR, BY, BZ, CA, CH, CN, CR, CU, CZ, DE, DK, DM, DZ, EE, ES, FI, GB, GD, GE, GH, GM, HR, HU, ID, IL, IN, IS, JP, KE, KG, KP, KR, KZ, LC, LK, LR, LS, LT, LU, LV, MA, MD, MG, MK, MN, MW, MX, MZ, NO, NZ, PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, TZ, UA, UG, US, UZ, VN, YU, ZA, ZW, AM, AZ, BY, KG, KZ, MD, RU, TJ, TM RW: GH, GM, KE, LS, MW, MZ, SD, SL, SZ, TZ, UG, ZW, AT, BE, CH, CY, DE, DK, ES, FI, FR, GB, GR, IE, IT, LU, MC, NL, PT, SE, BF, BJ, CF, CG, CI, CM, GA, GN, GW, ML, MR, NE, SN, TD, TG 19990812 US 1999-373486 B1 20020507 US 6383273 19990812 A2 PRAI US 1999-373486 Biocidal or an absorbent and/or catalyst compns. contg. (i) a biocidal silver or copper compd., (ii) a support consisting of carbon, a polymer, or a cellulosic fiber, and (iii) a reducing agent are prepd. and used against microorganism and for elimination of contaminants from the environment. ANSWER 4 OF 5 CAPLUS COPYRIGHT 2002 ACS L9 1998:430237 CAPLUS AN 129:84972 DN Nonflammable fibrous products, and their use ΤI Wihsmann, Marc; Ebner, Lothar IN Protekum Umweltinstitut G.m.b.H. Oranienburg, Germany PΑ Ger. Offen., 4 pp. SO CODEN: GWXXBX DΤ Patent LA German FAN.CNT 2 APPLICATION NO. DATE KIND DATE PATENT NO. -----DE 1996-19654836 19961223 19980625 A1 DE 19654836 PΙ EP 1997-954717 19971222 19991006 A2 EP 946809 B1 20011017 EP 946809 R: AT, BE, CH, DE, DK, FR, GB, LI, LU, NL, SE 20011115 AT 1997-954717 19971222 E AT 207150

20000711

Α

PRAI DE 1996-19654836 A 19961223

US 6086998

19990618

US 1999-331388

19961223 DE 1996-29622593 U WO 1997-DE3031 W 19971222 The fibrous products contain cellulose fibers 20-70, CaCO3 15-45, cationic AΒ surfactant 0.01-1, biol. active, in water not readily sol. surfactant 0.05-1, or CaO2 0.25-6.5 wt.\$, and balance fillers, and, optionally, .gtoreq.1 biocides. The fillers are selected from .gtoreq.1 of Al203, SiO2, MgO, Ca silicates, aluminosilicates, BaSO4, Na2CO3, KCl, K2CO3, CaF2, and Fe oxides. The fibrous products are used as blown thermal insulation, for manufg. molded products, and as fire-resistant and thermally insulating panels. ANSWER 5 OF 5 CAPLUS COPYRIGHT 2002 ACS Ь9 1998:352913 CAPLUS ΑN DN 129:45355 Biocidal corrosion inhibiting compositions TIGreen, Bruce Phillip ΙN Health and Hygiene International Pty. Ltd., Australia; Green, Bruce PA PCT Int. Appl., 22 pp. SO CODEN: PIXXD2 DTPatent LA English FAN.CNT 1 KIND DATE PATENT NO. ____ _____ WO 1997-AU784 WO 9822554 A1 19980528 PΙ

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DATE
                                           APPLICATION NO.
                                                            19971118
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            PL, PT, RO, RU, SD, SE, SG, SI, SK, SL, TJ, TM, TR, TT, UA, UG,
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                                           AU 1998-51105
                                                            19971118
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                      A1
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                                           EP 1997-945666
                                                            19971118
    EP 1009781
                      A1
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            IE, FI
PRAI AU 1996-3710
                            19961118
                       Α
    WO 1997-AU784
                       W
                            19971118
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AB The compns. for use in combination with a strong oxidizing agent comprise .gtoreq.l arom. triazole, .gtoreq.l molybdate salt and .gtoreq.l nitrate salt. A method of cleaning and sterilizing a surface (such as medical instruments) comprises contacting the surface with a strong oxidizing agent and a corrosion inhibiting compn.